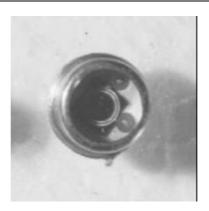
P-TYPE SILICON PIN PHOTODIODE FD5P1



PIN photodiode FD5P is optimized for detection of radiation at 1060nm. A photodiode illuminated by visible and near infrared light behaves as a current source with photocurrent proportional to the power of detected radiation. Reverse bias increases parallel internal resistance and decreases capacity of diode. Decrease of capacity and of load resistance R_L decreases response time. Low capacity with relatively low bias is achieved by using extremely pure, high resistance silicon for the base I-region of the diode (> 10 k Ω cm). Background radiation flux increases noise current, thus filters or darkening are recommanded to decrease this radiation.

FFATURES

- Guard ring construction
- Peak responsivity at 1060nm
- Short response time
- Low capacity
- Low noise
- Low dark current
- Wide spectral range
- · Linearity over wide spectral range
- High reliability
- Fast delivery

APPLICATION

- NdYAG laser pulse detection
- Guidance, tracking and aligning
- Alarm systems
- Optical pyrometers
- Precision light meters

SPECIFICATIONS

• Ambient temperature25°C, DC reverse operating voltage 200V

Parameter	typical	min	max	Upon request, up to	Note
Breakdown voltage (V)	400	250		>450	1 μΑ
Dark current (nA)	20		50	<10	
Responsivity at 900 nm (A/W)	0.6	0.5		0.65	
Responsivity at 1060 nm (A/W)	0.45	0.40			
NEP at 900nm (x10 ⁻¹² W/Hz ^{1/2})	<1.5		10	<1	
NEP at 1060nm (x10 ⁻¹² W/Hz ^{1/2})	<2.5		15	<1.5	
Capacitance (pF)	2.8		3.0	2.65	1 MHz
Response time (ns)	11				900 nm, R=50Ω, 50%
Approx. full angle for totally illuminated active area (O)	105				The values are dependent on dimensional tolerances of the package
Approx. full angle for partially illuminated active area(⁰)	146				The values are dependent on dimensional tolerances of the package
Active area (mm ²)	5				

